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# 4H-SiC PiN diode protected by narrow field rings investigated by the micro-OBIC method

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**Abstract.** This paper presents micro-OBIC measurements performed at different voltages on two devices protected by narrow field rings. At the surface of the device #1, a polyimide layer was deposited during the fabrication process. In contrast, the passivation layer was removed on device #2. Thanks to the micro-OBIC micrometer spatial resolution and the spot size that was carefully focused, small gaps in the range of 1  $\mu\text{m}$  can be visible on OBIC profiles. Thus, the variation of the micro-OBIC signal accurately reflects the topology of each ring.

## Introduction

Silicon Carbide (SiC) is an attractive semiconductor material for high power and high temperature applications. To reach the expected breakdown voltage, an effective junction termination is required to spread the electrical field profile towards edges mitigating the crowding effect. Among different techniques used for periphery protection [1], Junction Termination Extension (JTE) is a well-known technique often chosen due to their relative design simplicity. However, the structure of the present paper relies exclusively on guard rings, a more challenging approach where small technological deviations on the rings position can completely negate the benefits of the periphery protection. To get the most from those rings, key parameters such as the distance between each ring and the number of rings must be carefully chosen. The efficiency of this periphery protection is optimal when the electric field at the edge of each ring is nearly equal for all rings. Optical Beam Induced Current (OBIC) technique is a non-destructive characterization technique used here to analyze the electric field distribution at the edge of the device periphery. OBIC is an alternative technique compared to other complicated methods like Kelvin Probe Force Microscopy (KPFM) and Electronic Beam Induced Current (EBIC) microscopy, for high resolution analysis of electronic devices. This technique has been used to investigate silicon diodes protected by field rings [2], with spacing greater than 10  $\mu\text{m}$ , as well as 4H-SiC PiN diodes protected by JTE [3], [4]. In this paper, micro-OBIC technique is applied to SiC high voltage bipolar diodes where the design of the guard rings is more tightly constrained to analyze the experimental behavior of the periphery protection with respect to the applied reverse voltage.

## Experimental Setup

In the micro-OBIC experimental setup, a 349 nm UV pulsed laser is used to generate electron-hole pairs (EHPs) in the sample due to the laser beam with energy greater than the band gap energy. A set of properly adjusted optics (mirrors, microscope objective ...) is inserted on the beam path to finally get a focused laser spot with a diameter of about 1-4  $\mu\text{m}$  as shown on Fig. 1. The sample is placed on

a motorized stage and the position is controlled with LabView (i.e. on X, Y, Z automatically and inclination  $\theta$  manually). The laser beam energy at the top surface of the device is high enough to generate electron-hole pairs (EHPs), so that an OBIC current could be measured. The micro-OBIC principle has already been described in [4].

The testbench allows us to realize a spatial mapping of OBIC signal, either on a (X, Y) plane or only on X (or Y) lines. For X or Y lines, the step between two displacements of the laser beam is 200 nm. The DUT can be reverse biased by applying voltage up to 500V thanks to the SMU (Source Measure Unit) Keithley 237.

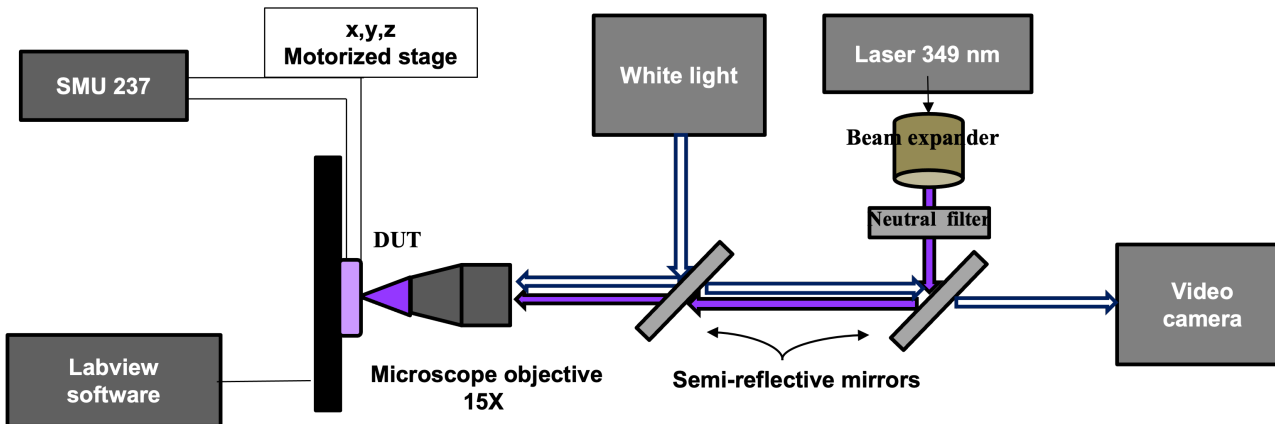


Fig. 1. Schematic representation of the micro-OBIC testbench.

The cross section of the DUT and its periphery is sketched on the Figure 2. For the sake of clarity, only one periphery protection is sketched in Fig. 2-a). The epilayer is  $14.8 \mu\text{m}$  thick, n-type doped ( $6 \times 10^{15} \text{ cm}^{-3}$ ). The main junction is realized by ion implantation, at the same time as the field rings, which were carefully designed by Caly Technologies. The diode is then protected by a passivation layer on the front side.

The measurements were realized on two different square-shaped bipolar diodes protected by field rings, namely device 1 and device 2, with and without passivation layer respectively.

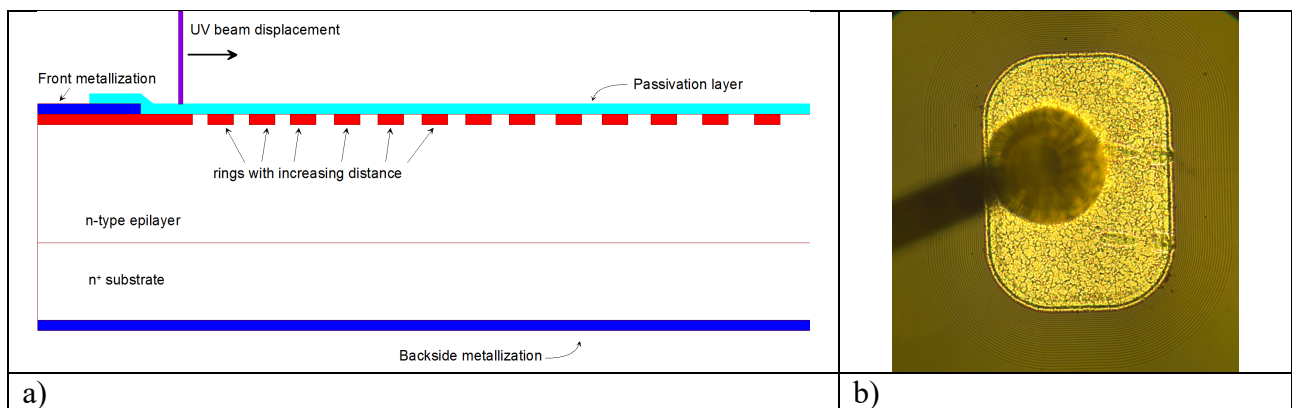


Fig. 2. a) Schematic cross section view of half vertical PiN diodes protected by 22 field rings (principle is sketched here only with 13 rings), b) photograph of the diode with the  $50 \mu\text{m}$  (diameter) gold ball bonding

The metallized anode contact is square-shaped, with a side length of  $200 \mu\text{m} \times 300 \mu\text{m}$ , and a corner curvature radius of  $200 \mu\text{m}$  as shown in Fig. 2-b).

This non-destructive technique allows to measure OBIC currents by scanning the outer edge of the biased diode, in order to assess the periphery protection efficiency. OBIC current increases as the electric field intensity increases in the structure. There is no OBIC current on the metallization, neither far from the periphery of the diode. These OBIC current profiles would come in handy to the designer to optimize the breakdown voltage. The diode is protected by 22 field rings as shown in Fig. 2, with

increasing spacing between them ( $0.07 \mu\text{m}$  from one ring to the next). The distance between the main junction and the first ring is  $1.2 \mu\text{m}$ . All the rings have the same width ( $1.5 \mu\text{m}$ ).

Inside a vacuum probing chamber, on-wafer measurements of the devices demonstrated a stable blocking voltage up to 2 kV as shown in Fig. 3.

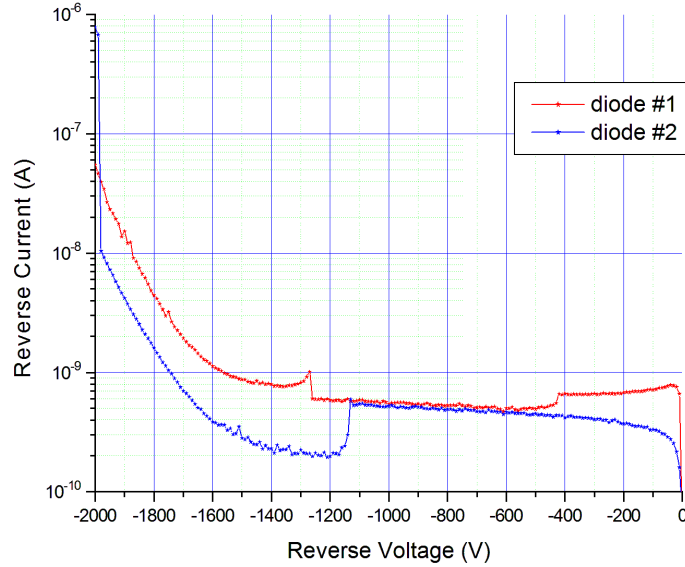


Fig. 3 Reverse characteristics of both devices (diode #1 with polyimide passivation, diode #2 without any passivation)

## Results and Analysis

By applying different reverse voltages (up to 500V) to the same diode and re-scanning the very same location, several OBIC currents can be compared to each other, as shown in Fig. 4. As the reverse voltage increases, the OBIC current increases for the same location, due to the increase of the electric field. One can also observe the extension of the space charge region as the reverse voltage increases and the role of outer field rings, witness of the peripheral protection good design.

As the reverse voltage increases, the number of OBIC peaks increases. From  $20 \mu\text{m}$  up to  $97 \mu\text{m}$ , each maximum is related to the presence of a ring as described in [1] and, more precisely, is located on the outer edge of each ring junction. As the reverse voltage increases, the presence of the rings is more clearly revealed by  $\mu$ -OBIC. Indeed, the number visible rings by OBIC increase with the reverse voltage. These measurements up to 500V, show the presence of very close rings (between  $1.2 \mu\text{m}$  for the first two rings and  $2.67 \mu\text{m}$  for the last two rings). One can count all the 22 field rings for a reverse voltage of 500V plus one more peak for the border of the main junction. That means that at 500V all the rings are revealed by the OBIC method.

The amplitude of the maximum doesn't increase much from one voltage to another. The distance between the peaks is in total accordance with the layout of the rings as shown in the figure and in Table 1. Table 1 gives the position of the first 11 rings based on its left lateral edge that is oriented towards the main junction when viewed from the cross-section depicted in fig.2a. The OBIC signal amplitude is given for each left lateral edge. Comparing the data from Table 1 and the OBIC profile shown in Fig. 4, each dip in the profile perfectly matches with the left lateral edge of each ring. All the data in the table 1, were extracted from diode #2 biased under 500 V.

Table 1: Distance from the main junction for ring mask layout and respective OBIC signal values.

Ring number	#1	#2	#3	#4	#5	#6	#7	#8	#9	#10	#11
Distance from main	1.2	3.97	6.81	9.72	12.7	15.75	18.87	22.06	25.32	28.65	32.05

junction ( $\mu\text{m}$ )											
OBIC signal	1.19	3.99	6.99	9.79	12.79	16	18.8	22.21	25.38	28.79	32.2

After measuring diode #1, some scratches appeared at the surface of the device under test, due to the sweeping of the laser. In fact, this device was passivated with a polyimide layer, allowing a uniform and homogeneous spreading of the electric field as shown in Fig. 4, and the opportunity to test the DUT without package, i.e. avoiding any electrical arcing in the air. With respect to the beam penetration, this additional layer acts as a UV light filter and then can be physically altered, consequently the OBIC signal is reduced by a factor of 100 approximately. Nonetheless, Figure 4 shows the benefits of polyimide layer at the top in terms of electric field distribution: at 500V the OBIC current is almost constant whereas Figure 5 shows a decrease in OBIC current value. For diode #1 one can observe all the rings from 300V.

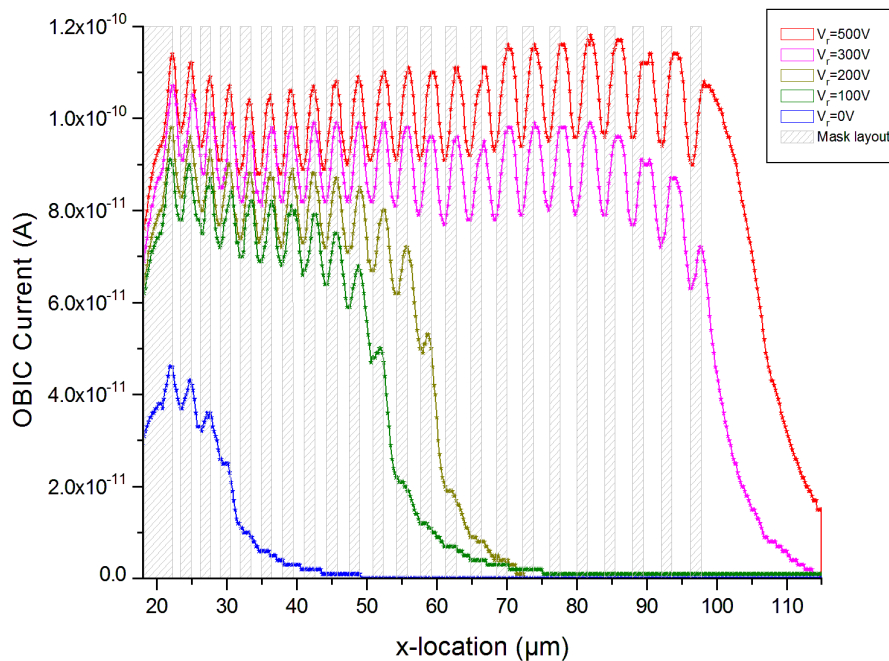


Fig. 4. OBIC currents at the periphery of the diode device #1 (with polyimide) for different reverse voltages (ranging from 0V up to 500V). The mask layout with the spacing between the rings is in grey color.

In order to study the periphery protection without any passivation layer, the polyimide was removed with a very high-density plasma on a new die. Then, the same experiment has been performed on diode #2 without polyimide layer at the top. The applied reverse voltage was also limited to 500V. The results are shown in Fig. 5. For diode #2 One can observe all the rings from 400V.

Compared to the previous measurements on both devices, performing measurements without the polyimide layer gives OBIC profile that reflects the peripheral protection more regular. In both cases, the peaks are related to the distance between the rings, and that is true even for very small distance as low as 1.2  $\mu\text{m}$ . More investigation is needed to properly discriminate the electrical effect of the passivation layer and its optical effect as a light filter.

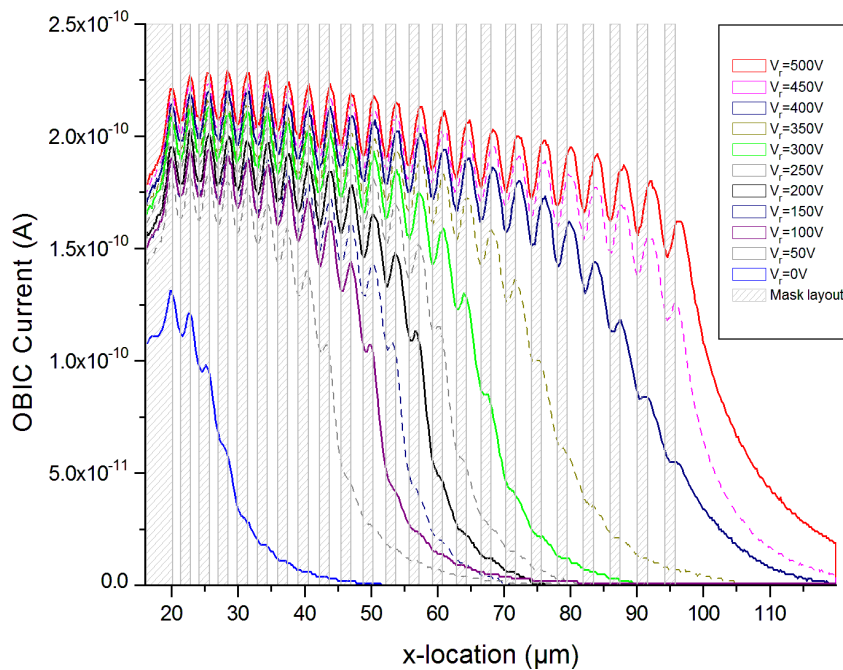


Fig. 5. OBIC currents at the periphery of the diode device #2 (without polyimide) for different reverse voltages (ranging from 0V up to 500V by 50V step). The mask layout with the spacing between the rings is in grey color.

## Summary

This paper presents OBIC measurements performed on field rings protected bipolar diodes at different voltages. This test-bench has a well improved spatial resolution compared to the previous OBIC test-bench. We estimated theoretically and experimentally the spatial resolution of the micro-OBIC to be around 1-4  $\mu\text{m}$ . A better resolution is interesting to characterize peripheral protections, such as JTE rings, whose lateral extension is of the order of magnitude of the micron.

JTE rings are directly observable in these experiments, even with narrow distances between each 22 rings. In the near future, this study will be completed by measurements at higher reverse bias under vacuum and to be closed to the breakdown voltage of the device (1 700 V). Indeed, we could transfer the  $\mu$ -OBIC test bench into a vacuum 10 kV chamber. It would be also interesting to study these same diodes by other complementary characterization methods such as micro-Raman spectroscopy, SEM/EDX and TOF-SIMS.

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